



Highly Efficient RF Lightwave Integrated Transmitters

Contract DAAD17-01-C-0077

RFLICS PI Review

El Segundo, CA 7/31/01

Dr. Won T. Tsang (Dr. Randall Wilson – presenting)

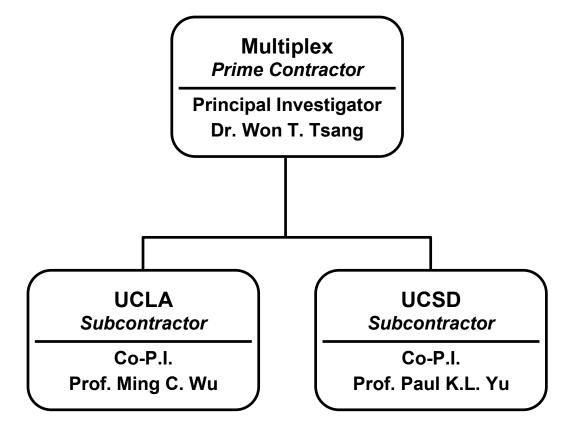








Team Management











RFLICS Goals

Develop the key components for a RF-photonic link that meets the following specifications:

- Transmit/process RF signal in the 0.5-50GHz range
- Broadband (>40GHz)
- High spurious-free dynamic range (SFDR >100dB-Hz^{2/3})
- Low loss or with RF gain (>-1dB)
- Monolithically integratable for low cost.









Multiplex/UCLA/UCSD Program Goals

- Traveling-Wave Electroabsorption-Modulated Laser Modules (TW-EML):
 - Develop low-Vpi (<0.5V), broadband (>40GHz) traveling-wave semiconductor electroabsorption modulators (EAM).
 - Monolithically integrate with distributed feedback (DFB) lasers using selective-area growth (SAG) by metal organic chemical vapor deposition (MOCVD).
- Optical Injection Locking of Gain-lever Laser Modules:
 - Develop a RF-photonic transmitter link by combining strong optical injection locking with gain-lever modulation.
 - Enhance the direct modulation bandwidth to achieve >40GHz operation.
 - Improve the RF modulation efficiency by 20dB (link gain improved by 40dB).
 - Reduce relative intensity noise (RIN) of the laser by 10 to 20 dB by using strong optical injection locking.

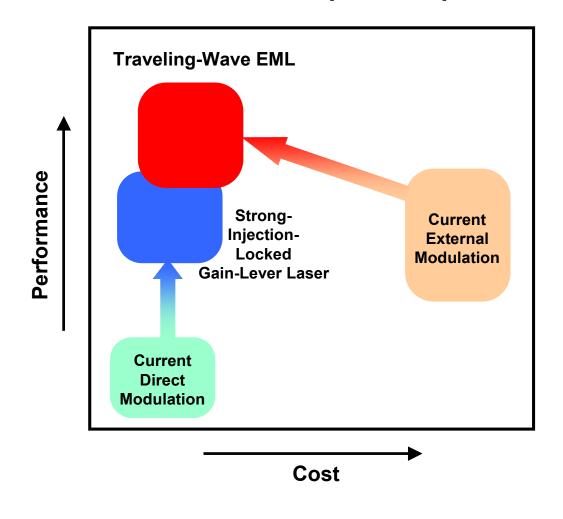








Objective of RF-Lightwave Integrated Transmitters (RFLIT)









Program Roadmap



Federal Government Fiscal Year		FY'01		FY'02				FY'03					FY'04				FY'05			
Calendar Year	2001				2002				2003				2004				2005			
Task Name	Q1	Q2	Q3	Q4	Q1	Q2	Q3	Q4	Q1	Q2	Q3	Q4	Q1	Q2	Q3	Q4	Q1	Q2	Q3	Q4
1.0 Travelling Wave EML																				
1.1 EML on SI Substrate Development						♦	1													
1.2 Travelling Wave EML Development							♦	2												
1.3 Low Vpi Modulator Development								♦	3											
1.4 High Frequency Package Development										♦	4									
1.5 Traveling Wave-EML Link Characterization															♦	5		♦	6	
2.0 Optical Injection Locking of Gain-Lever Laser Dev.																				
2.1 Gain-Level DFB Laser Development					♦	7														
2.2 Tunable DFB Laser Development							♦	8												
2.3 Optical Injection Locking									♦	9										
2.4 Direct Modulation Laser Package Development										♦	10									
2.5 Direct Mod. Characterization with Strong Inj. Locking													•	11				•	12	







Milestones and Deliverables

Milestone	Task	Milestone/Deliverable
1	1.1	Complete development of baseline EML technology on SI-InP
2	1.2	Complete development of 1 st generation TW-EML
3	1.3	Complete development of 1 st generation TW-EML with low Vpi
4	1.4	TW-EML high frequency package complete. Link characterization of 1 st gen TW-EML complete. Deliver alpha prototype TW-EML
5	1.5	Link characterization of 2 nd gen TW-EML complete. Deliver beta prototype TW-EML
6	1.5	Link characterization of 3 rd gen TW-EML complete. Deliver final prototype TW-EML
7	2.1	Complete development of 1 st generation Gain-Lever DFB
8	2.2	Complete development of 1 st generation Tunable DFB
9	2.3	Package development for high frequency Gain-Lever laser complete
10	2.4	Optical injection locking experiment complete using 1 st gen components from milestones 7 and 8.
11	2.5	Link characterization of optical injection locked Gain-Level DFB laser. Deliver beta prototype.
12	2.5	Link characterization of 2 nd gen optical injection locked Gain-Lever DFB. Deliver final prototypes.









Task 1.1 Detailed Schedule/Milestones

				1Q01		2Q01		3Q01		4Q01		1Q02	2Q02	
ID	Task Name	Duration	Jan	Feb	Mar	Apr May Jun	Jul	Aug Sep	Oc	t Nov	Dec	Jan Feb Mar	Apr May Jun	Jul
1	1.1 EML on SI Substrate	177d					•							
2	1.1.1 Baseline EML growth	121d											MTX	
3	1.1.1 Complete	0d											4/1/02 5:00 PM	1
4														
5	1.1.2 SAG and regrowth	121d											мтх	
6	1.1.2 Complete	0d							1	•			4/1/02 5:00 PM	1
7														
8	1.1.3 fabrication process	96d					•							
9	Share structure/mask set info. Formulate process seq.	5.2w						UCL	A,M	TX				
10	Design mask set using autocad.	2w						<u> </u>	ITX					
11	procure mask levels from vendor	4w								MTX				
12	Grow wafer, process wafer	8w							1	,	МТ	X		
13	1.1.3 Complete	0d									1 2	2/7/01 5:00 PM		
14														
15	1.1.4 MOCVD growth approaches	112d										UCSD		
16	1.1.4 Complete	0d									•	12/31/01 5:00 F	M	
17														
18	1.1.5 Material loss characterization	56d					•							
19	Specification of test structure	26d						ucs	D					
20	Calibration and growth to deliver 1 wafer	3w							MTX	,				
21	Fab wafer and test	3w								UCSD				
22	1.1.5 Complete	0d							•	10/12/0	1 5:00	PM		
23														









Task 2.1 Detailed Schedule/Milestones

	1	1	1001			1Q01 2Q01						4Q01	1Q02			2Q02			
ID	Task Name	Duration	Jan		Mar		May	Jun	Jul	3Q01 Aug Sep	Oct		Jan		Mar	Apr			Jul
23	Table Name	Daration	Juni	1 00	IVIGI	, (p.]	way	Juli	- Oui	/ tug	000	11101 20	Journ	1.00	iviai	7 (2)	iviay	oun	oui
24	2.1 Gain-Lever DFB Laser Development	112d							•	,			┢						
25	2.1.1 Initial prototype development	45d							Ţ	,									
26	Calibrate and grow wafers	4w							-	МТХ									
27	Design mask	4w								UCLA									
28	Fab wafer	4w									ÜCLA								
29	Test device	1w									UCL	A							
30	2.1.1 Complete	0d								•	9/2	7/01 5:00 F	М						
31																			
32	2.1.2 Modeling of design and select optimum	112d											UCL	Α					
33	2.1.2 Complete	0d											12/	31/01	5:00 F	M			
34																			
35	2.1.3 Develop manufacturing process for selected design	13w											МТХ						
36	2.1.3 Complete	0d											1 2/	31/01	5:00 F	M			
37																			
38																			









Most Significant Accomplishment

- Contract Awarded June 6, 2001
- Traveling Wave Electro-Optical Models at both UCLA and UCSD are operational and are producing favorable results and predictions ready to be compared with experiment.







RFLIT: Electroabsorption Modulator for Broadband Access



Paul Yu -UCSD

A. Is there traveling-wave effect in short device?

Traveling wave model
How the traveling-wave model migrates to lumped-element model
How to break the RC-bandwidth-limit rule by TW-EAM design

B. The design and performance of TW-EAM devices fabricated at UCSD

Device structure
Microwave properties of the waveguide
Modulation frequency response and bandwidth
Optical saturation power

C. Current Investigation

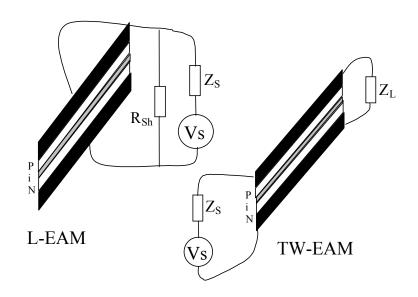




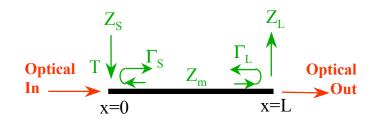




Electrical Connections of L-EAM and TW-EAM



To achieve maximum link RF gain, the best waveguide length has been $\sim 200 \, \mu m$ for both L-EAM and TW-EAM. (limited by optical propagation loss)



Both are $\sim 200 \ \mu m \log$.

Are there any advantages for the electrical connection to TW-EAM?

$$\Gamma_{\rm S} = \frac{Z_{\rm S} - Z_{\rm m}}{Z_{\rm S} + Z_{\rm m}}$$
 $\Gamma_{\rm L} = \frac{Z_{\rm L} - Z_{\rm m}}{Z_{\rm L} + Z_{\rm m}}$
 $\Gamma = \frac{2Z_{\rm m}}{Z_{\rm S} + Z_{\rm m}} = 1 - \Gamma_{\rm S}$









Circuit Model for TW-EAM

Small-segment lumped-element circuit model for TW-EAM transmission line.

$$Z_{\text{series}} = R_{\text{con}} + j\omega L_{\text{m}}$$

$$Z_{\text{series}} = R_{\text{con}} + j\omega L_{\text{m}}$$

$$Z_{\text{shunt}} = R_{\text{S}} + \frac{R_{\text{O}}}{1 + j\omega R_{\text{O}} C_{\text{m}}}$$

$$Z_{\text{series}} = R_{\text{con}} + j\omega L_{\text{m}}$$

$$Z_{shunt} = R_s + \frac{R_o}{1 + j\omega R_o C_m}$$

$$Z_{\rm m} = \sqrt{Z_{\rm series} Z_{\rm shunt}}$$

$$Z_{\rm m} = \sqrt{Z_{\rm series} Z_{\rm shunt}}$$
 $\gamma_{\mu} = \alpha_{\mu} + j \beta_{\mu} = \sqrt{\frac{Z_{\rm series}}{Z_{\rm shunt}}}$

Modified TW-EAM frequency response:

$$M'(f) = M(f) \left| \frac{Z_{junc}}{Z_{shunt}} \right|^{2} \qquad Z_{junc} = \frac{R_{O}}{1 + j\omega R_{O}C_{m}}$$

$$Z_{junc} = \frac{R_O}{1 + j\omega R_O C_m}$$









From TW-EAM to L-EAM

$$M(f) = \left| \frac{T}{e^{\gamma_{\mu}L} - \Gamma_{L}\Gamma_{S}e^{-\gamma_{\mu}L}} \left\{ \frac{e^{j\beta_{o}L} - e^{\gamma_{\mu}L}}{(j\beta_{o} - \gamma_{\mu})L} + \Gamma_{L} \frac{e^{j\beta_{o}L} - e^{-\gamma_{\mu}L}}{(j\beta_{o} + \gamma_{\mu})L} \right\} \times \frac{Z_{junc}}{Z_{shunt}} \right|^{2} \qquad \qquad \begin{aligned} & \text{For L-EAM:} \\ & \Gamma_{L} = 1, \\ & L \text{ is very short.} \end{aligned}$$

$$\Gamma_L$$
=1,
L is very short

$$= \left| \frac{T}{e^{\gamma_{\mu}L} - \Gamma_{S}e^{-\gamma_{\mu}L}} \{1 + 1\} \times \frac{Z_{junc}}{Z_{shunt}} \right|^{2} = \left| \frac{2(1 - \Gamma_{S})}{(1 - \Gamma_{S}) + \gamma_{\mu}L(1 + \Gamma_{S})} \times \frac{Z_{junc}}{Z_{shunt}} \right|^{2}$$
 T=1-\Gamma_{S}

$$T=1-\Gamma_S$$

$$= \left| \frac{2Z_{junc}}{Z_{shunt} + LZ_{s}} \right|^{2}$$

$$= \frac{2Z_{\text{junc}}}{Z_{+} + LZ_{\text{o}}}^{2} \qquad \frac{1 + \Gamma_{\text{s}}}{1 - \Gamma_{\text{s}}} = \frac{Z_{\text{s}}}{Z_{\text{m}}} \qquad \frac{\gamma_{\mu}}{Z_{\text{m}}} = \frac{1}{Z_{\text{shunt}}}$$

$$= \left| \frac{2}{1 + j\omega C_{\rm m} L(Z_{\rm S} + R_{\rm S}/L)} \right|^2$$

$$= \left| \frac{2}{1 + i\omega C_{m} L(Z_{s} + R_{s}/L)} \right|^{2}$$
Assume $Z_{junc} = \frac{1}{j\omega C_{m}}$ $Z_{shunt} = R_{s} + \frac{1}{j\omega C_{m}}$

- 1). L-EAM means both short-length and open-termination,
- 2). Proper termination for short TW-EAM could break RC-limit rule for bandwidth,
- 3). Velocity-matching is not very important.





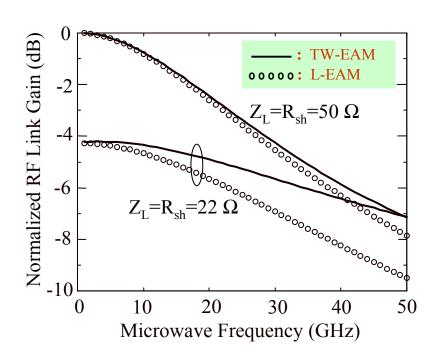




Breaking the RC-Limit Rule for Modulation Bandwidth

Comparing L-EAM and TW-EAM with the same optical waveguides:

L=0.2mm, L_m= 0.5 nH/mm, C_m=1.2 pF/mm, R_{con}=3.5 Ω-mm⁻¹GHz^{-1/2}, R_S=1 Ω-mm, R_O=10⁶ Ω-mm, n_o=3.5



3-dB bandwidth:

	$Z_L=R_{sh}=50 \Omega$	$Z_L=R_{sh}=22 \Omega$
L-EAM	20 GHz	30 GHz
TW-EAM	21 GHz	50 GHz

Low impedance termination for TW-EAM can break the RC-limit rule for bandwidth

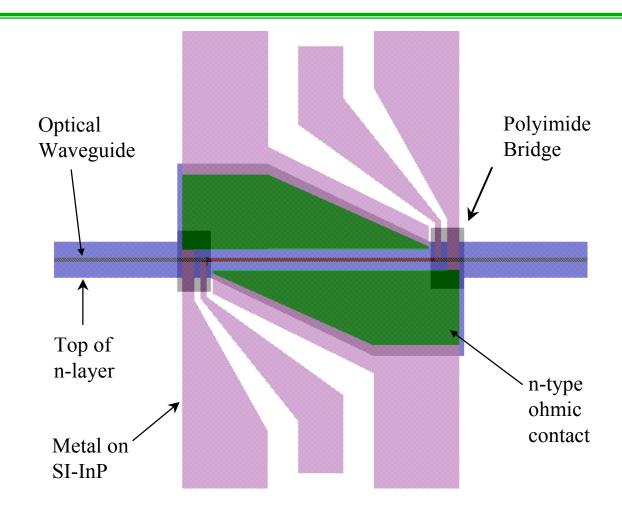








Device Top View



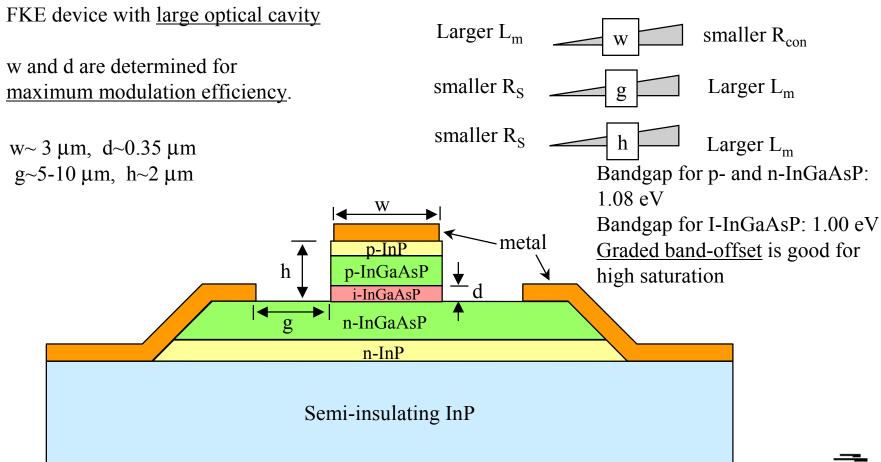








Device Design: Cross-section





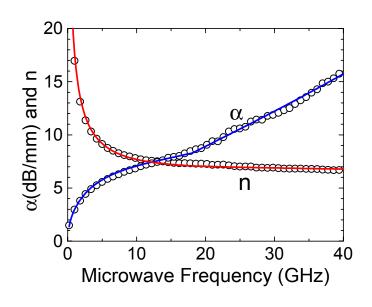


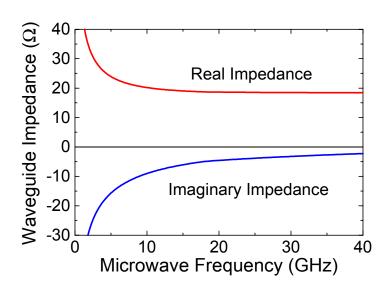




Waveguide Microwave Properties

For the fabricated TW-EAM device





De-embedded circuit parameters from curves of $\alpha(f)$ and n(f):

 $L_{m} \sim 0.40 \text{ nH/mm}, \ C_{m} \sim 1.3 \ \text{pF/mm}, \ R_{con} \sim 7.3 \ \Omega \text{-mm}^{\text{-}1} \text{-GHz}^{\text{-}1/2}, \ R_{S} \sim 0.58 \ \Omega \text{-mm}.$



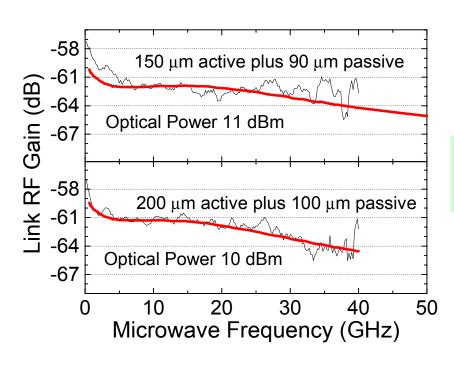






Device Frequency Response

Termination impedance 26.2 Ω . Detector RF responsivity ~0.12 A/W up to 40 GHz.



For 200 µm long L-EAM with the same optical waveguide:

 $C_m \sim 1.3*0.2= 0.26$ pF, $R_S \sim 0.58/0.2=3$ Ω , $R_{Sh} = 26.2$ Ω Assume 0.03 pF capacitance due to bonding pad. Modulation bandwidth ~ 25 GHz

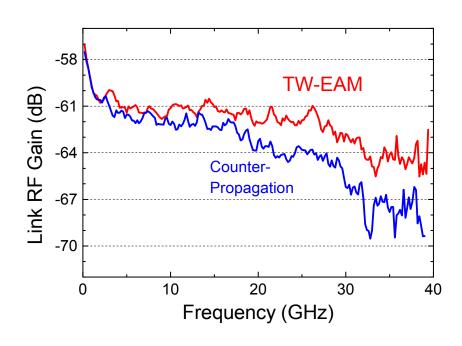








Counter-Propagation Measurement



200 μm long active length plus 100 μm long passive length

Input optical power: 11.5 dBm

Detector RF responsivity: ~0.20 A/W up to 40 GHz

Modulator optical loss: 11.5 dB

From 5 GHz, 3-dB cut-off: at 25 GHz for blue curve at 36 GHz for red curve

$$M(f) = \left| \frac{T}{e^{\gamma_{\mu}L} - \Gamma_{L}\Gamma_{S}e^{-\gamma_{\mu}L}} \left\{ \frac{e^{j\beta_{o}L} - e^{\gamma_{\mu}L}}{(j\beta_{o} - \gamma_{\mu})L} + \Gamma_{L} \frac{e^{j\beta_{o}L} - e^{-\gamma_{\mu}L}}{(j\beta_{o} + \gamma_{\mu})L} \right\} \times \frac{Z_{junc}}{Z_{shunt}} \right|^{2}$$









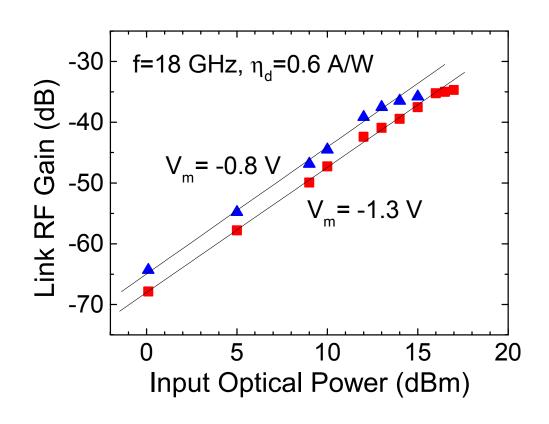
Optical Saturation Measurement

Two devices shown: 200 μm long modulation length plus 100 μm long passive section.

26.2 Ω termination.

optical saturation power @ 1-dB gain compression point:

25 mW and 45 mW respectively







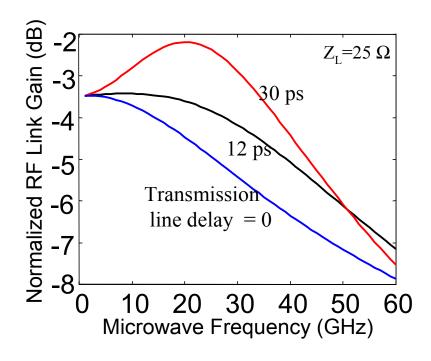




Current Investigations for TW-EAM with Larger Bandwidth

a. Increasing Waveguide Inductance

b. Design Terminator Transmission Line



Inductance is <1 nH/mm for an usual TW-EAM.









Summary

- 1. Traveling-wave design can improve performance for short device.
- 2. Low impedance termination for TW-EAM can break the RC-limit rule for the bandwidth.
- 3. The fabricated TW-EAM devices show good performance. bandwidth> 40 GHz, optical saturation power~45 mW.
- 4. Current Investigation underway for low V_{π} , large bandwidth EA modulator design for Traveling wave EML.







RF Lightwave Integrated Circuits (R-FLICS) PI Meeting July 31, 2001



Highly Efficient RF Lightwave Integrated Transmitters (RFLIT)

Ming C. Wu, UCLA

Graduate Students:
Sagi Mathai, Juthika Basak, Tom Jung, Erwin Lau

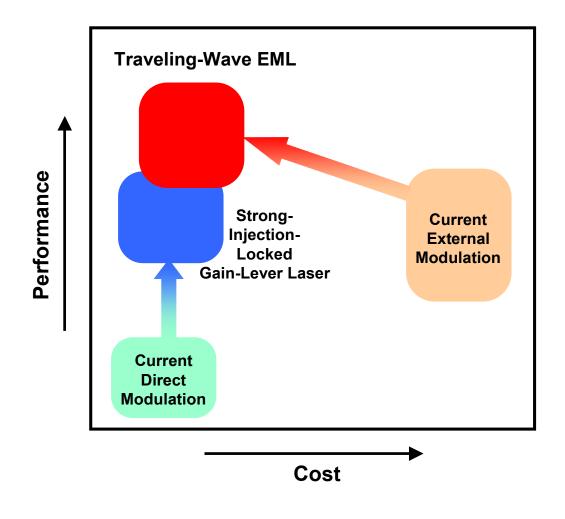
Collaboration:
Federica Cappelluti, Prof. Giovanni Ghione
Politecnico di Torino, Italy





Multiplex, Inc. Photonics for Cobjective of RF-Lightwave Integrated Transmitters (RFLIT)











Program Goals



- Team Goal:
 - Develop chip-scale RF Lightwave Integrated Transmitters (RFLIT) for high performance military and commercial RF systems:
- UCLA Goal:
 - Traveling-wave EML:
 - Design and modeling of EML
 - Assist in fabrication of prototype EML
 - Directly modulation with strong optical injection locking
 - Enhance bandwidth with strong optical injection locking
 - Enhance efficiency with split-contact (gain-lever) modulation
 - Comprehensive modeling
 - Fabrication and experimental demonstration





Multiplex, Inc. Photonics for Communication Self-Consistent Time-Domain Large Signal of TW-EAMs



- TW-EAMs models proposed so far are derived in quasistatic conditions and exploit linear approximations of microwave and optical parameters.
- Several nonlinear effects take place in TW-EAMs:
 - Absorption is a nonlinear function of applied voltage
 - Photocurrent causes non-uniform microwave losses and saturates at high optical power
 - Propagation characteristics of the microwave electrodes depend on the applied voltage through the photocurrent and, to a lesser extent, through the nonlinear junction capacitance
- Frequency-domain linear models cannot account for the RF and optical power induced nonlinear behavior, even at a small signal level

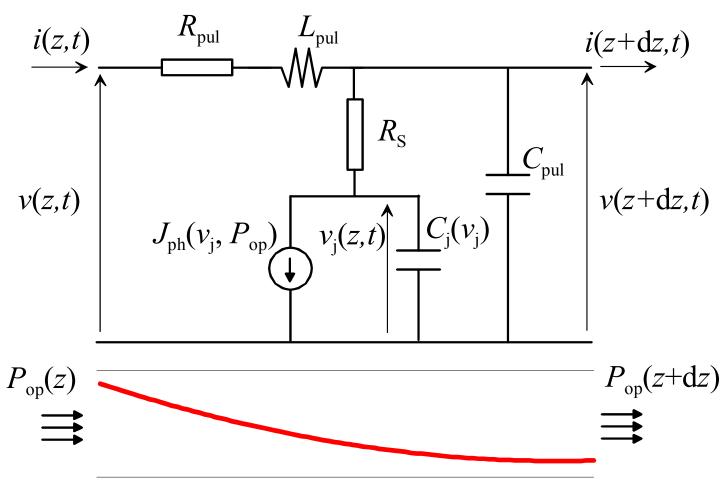






The Dynamic TW-EAM Model (I)













- Microwave and optical fields propagation equations coupled through:
 - voltage and optical power dependence of the photogenerated current
 - microwave losses induced from the photogenerated current
- Empirical formulas were used for the voltage and optical power dependence of the absorption
- Coupled equations implemented in the time domain
- Numerical solution of the equations obtained following a first order finite difference approach
- System solved self-consistently through a semi-implicit method



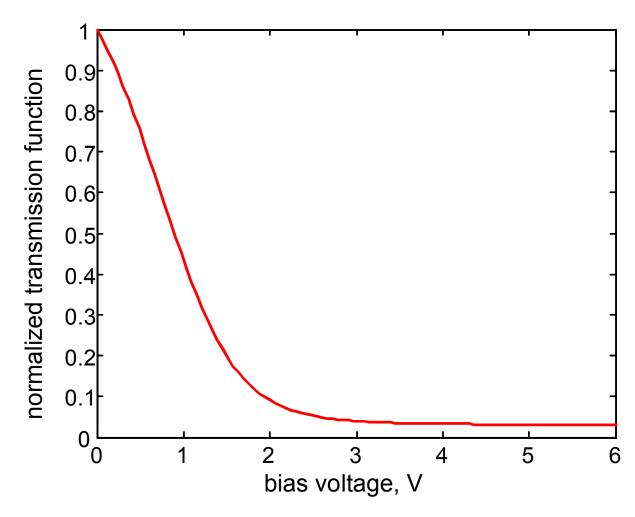




Results



Simulations performed on a 200 μm long EAM:



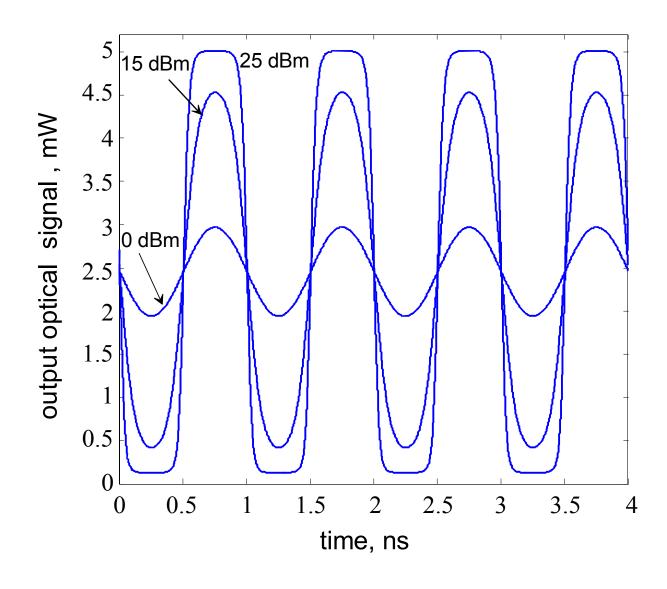






Time Domain Optical Waveforms





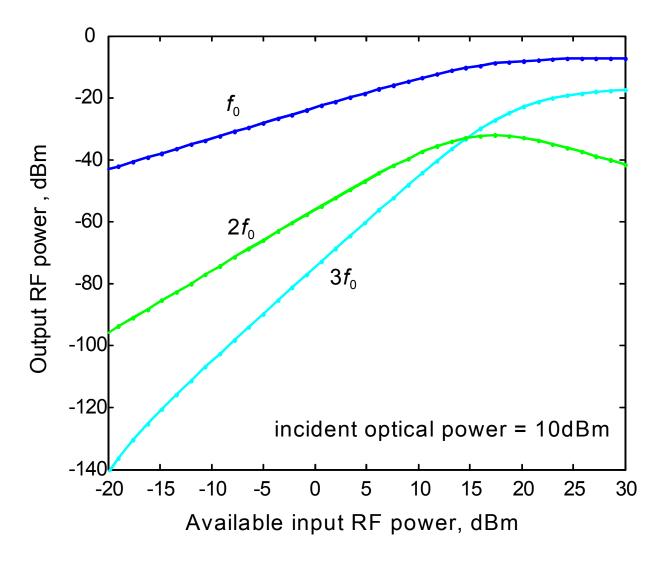






Saturation and Nonlinear Distortions





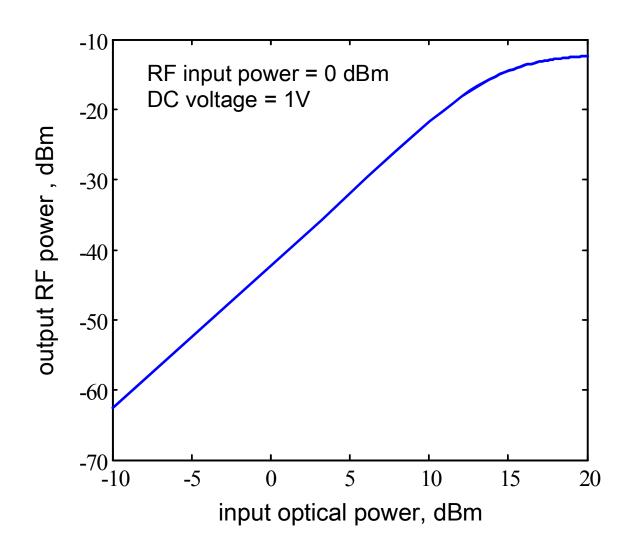






Optical Power Induced Saturation









Multiplex, Inc. Photonics for Commun Directly Modulated RF Lightwave Transmitters



- Direct modulation of semiconductor laser
 - → Compact, simple, low cost
- Disadvantages of direct modulation:
 - Low optical-RF conversion efficiency
 - Bandwidth limited by relaxation oscillation frequency
 - Large nonlinear distortion
 - Chirp
 - High RIN
- Has been primarily used in low performance systems





Multiplex, Inc. Photonics for Copirectly Modulated Laser with Strong Optical Injection Locking



- Strong optical injection locking significantly enhance the performance of direct modulation:
 - Increase the modulation bandwidth to beyond the fundamental limit of relaxation oscillation
 - Reduce nonlinear distortions
 - Reduce RIN
 - Reduce chirp
- Enhance the modulation efficiency using gain-lever effect



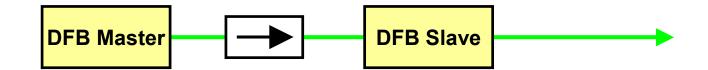




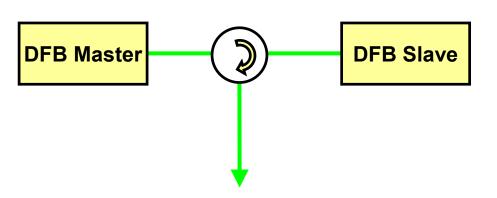
Injection Locking Set-up







Reflection Type

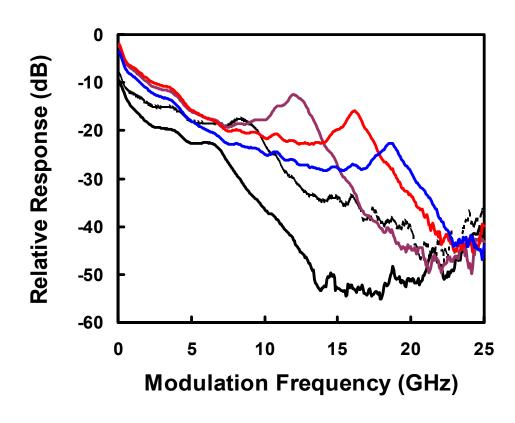






Multiplex, Inc. Photonics for C Modulation Dynamics of Directly Modulated DFB Laser with Strong Optical Injection





- Enhance modulation bandwidth
 - Relaxation oscillation frequency increased by 4 times
- Resonant peak height controlled by detuning frequency

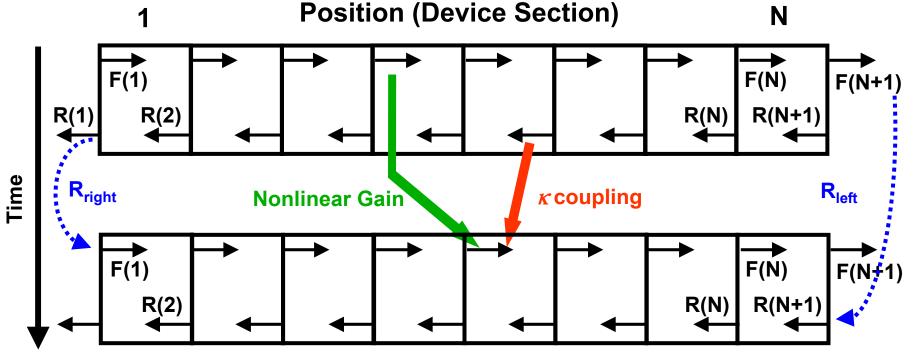






FDTD Modeling of DFB Lasers





Coupled Traveling Wave Equations

$$\frac{1}{c_g} \frac{\partial F}{\partial t} + \frac{\partial F}{\partial z} = (g - \alpha_L - i\delta)F + i\kappa R \qquad \frac{1}{c_g} \frac{\partial R}{\partial t} - \frac{\partial R}{\partial z} = (g - \alpha_L - i\delta)R + i\kappa F$$

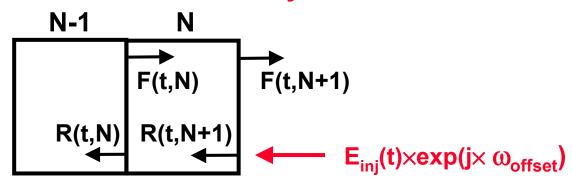




Multiplex, Inc. Photonics for Communication Communication



Modified Boundary Conditions



Injection Ratio:

$$\eta = E_{inj} / F(N+1)$$
 (free-running)

Boundary Conditions:

$$R(t+1,N) = F(t,N+1) \times R_{right}$$

Boundary Conditions with Optical Injection:

$$R(t+1,n+1) = F(t,n+1) \times R_{right} + E_{inj}(t) \exp(j\omega_{offset})$$





Multiplex, Inc. Photonics for Communications Advantages of FDTD Modeling of DFB Lasers and Optical Devices

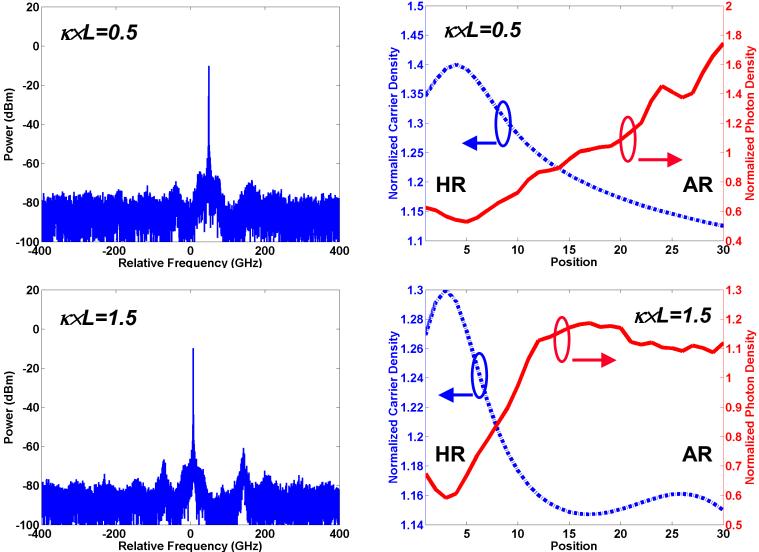


- Accurately models the non-uniformities in the device
 - Spatial Hole Burning (SHB)
 - Non-uniform current injection (Split Contact Modulation Techniques)
- Models the cavity effects
 - Device characteristics for different kxL products and facet reflectivities
 - Complex coupled DFB lasers can be modeled
- Multimode model
 - Takes into account other cavity modes and predicts side-mode suppression
- Model integrated photonic devices
 - EML residual reflections at the interfaces





Multiplex, Inc. Photonics for Communic Stimulated Optical Spectrum of DFB Laser for Various $\kappa \times L$ Products (HR-AR Coating)

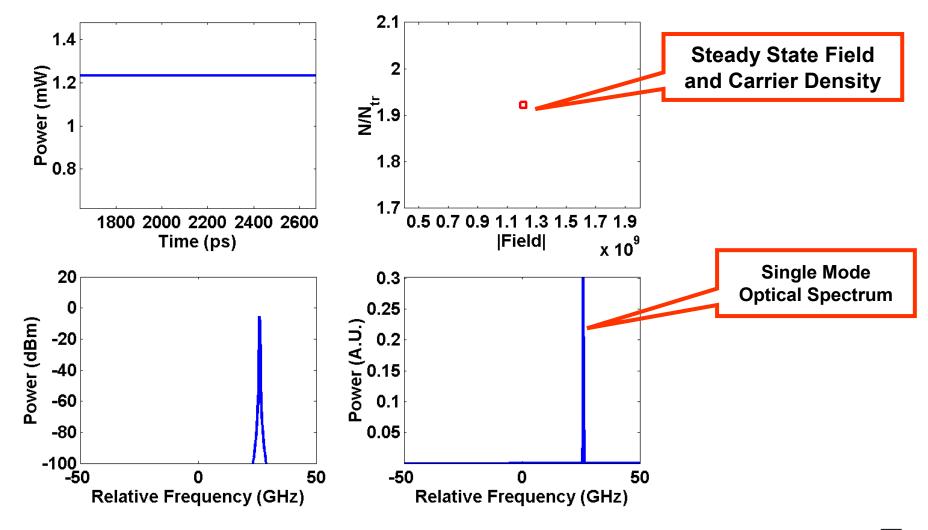






Multiplex, Inc. Photonics for Communication Stable Injection Locking Laser Dynamics





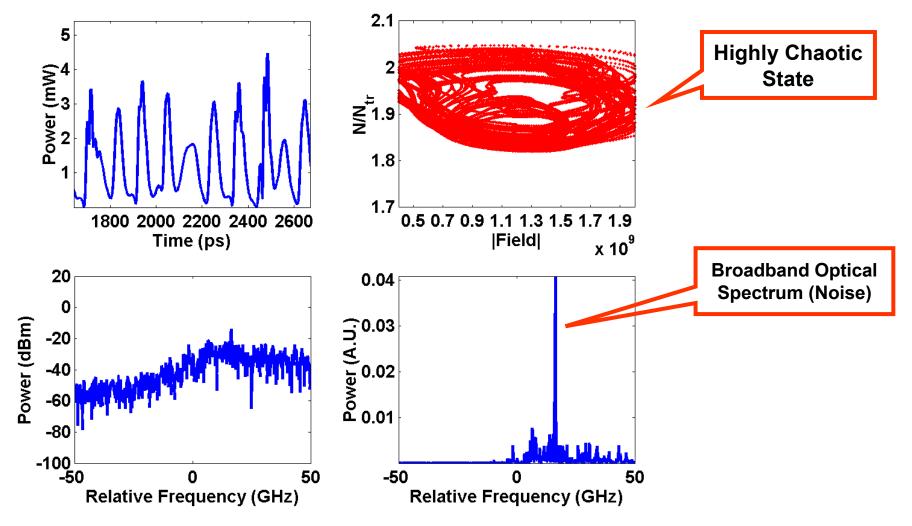






Multiplex Inc. Photonics for Com Common Laser Dynamics Caused by **Optical Injection**



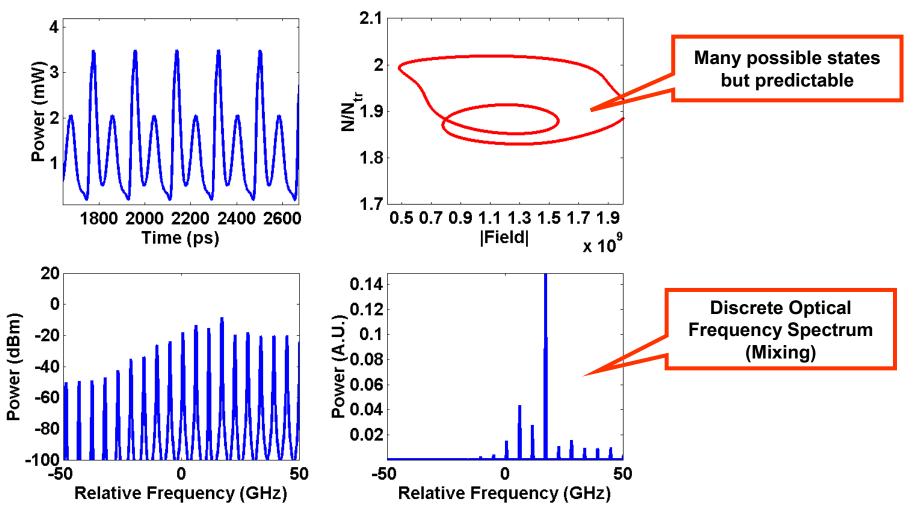






Multiplex, Inc. Photonics for Communications Periodic Optical Mixing in Semiconductor Lasers (Limit Cycle)



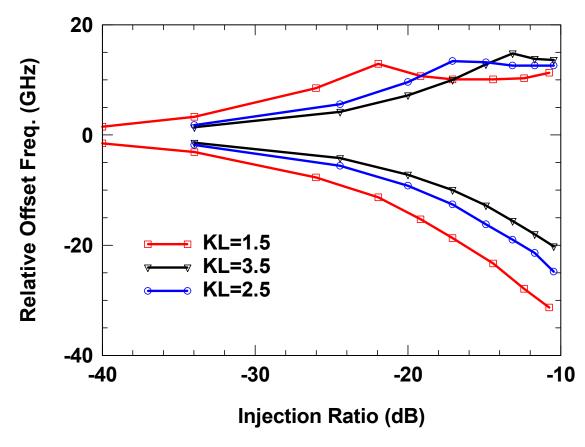






Multiplex, Inc. Photonics for Simulated Locking Range for Various Various $\kappa \times L$ Products



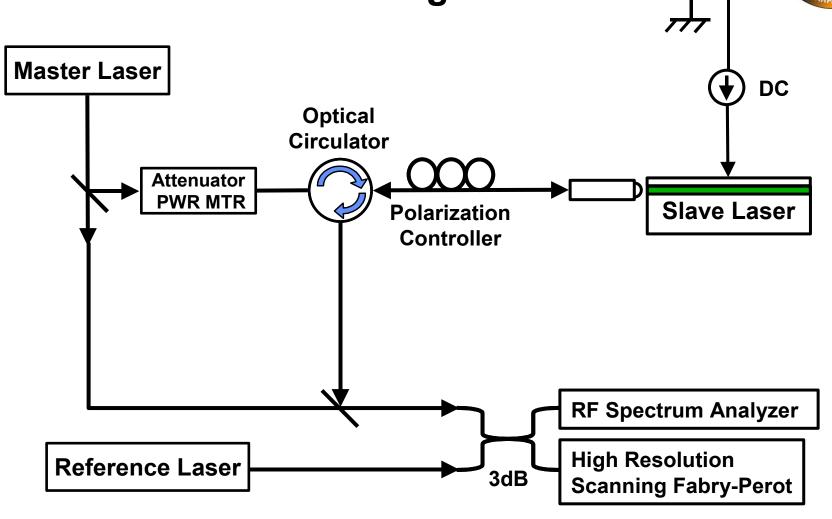


- Locking range is symmetrical at low injection levels
- Size of stable locking range is a strong function of gain saturation





Multiplex, Inc. Photonics Experimental Set-up for Optical Injection Locking



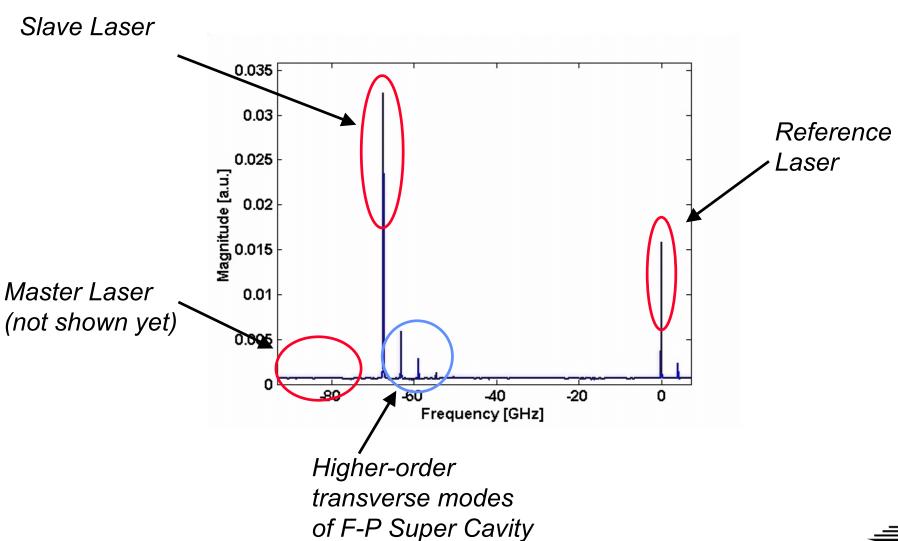






Injection Locking Visualization





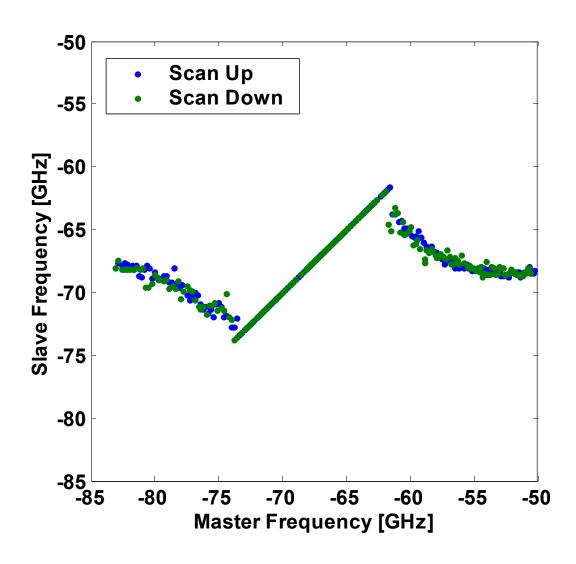






Locking Range





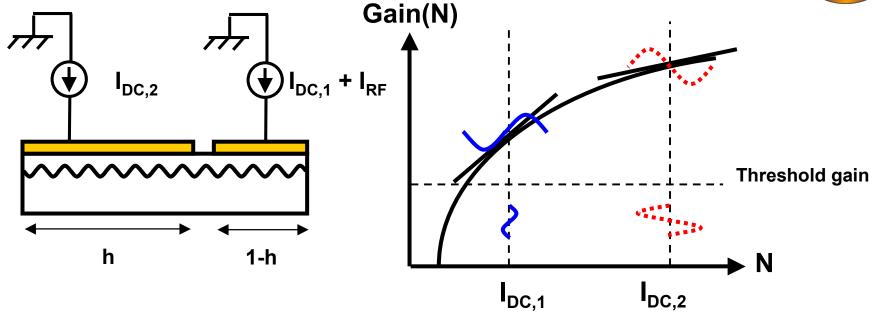




Multiplex, Inc. Photonics for Communications

Gain Lever Modulation Using Semiconductor Lasers





- First demonstrated by Dr. Kam Lau ('89) using FP lasers
- Lasing Condition:

Total Gain = Gain in Section 1 + Gain in Section 2 = Constant

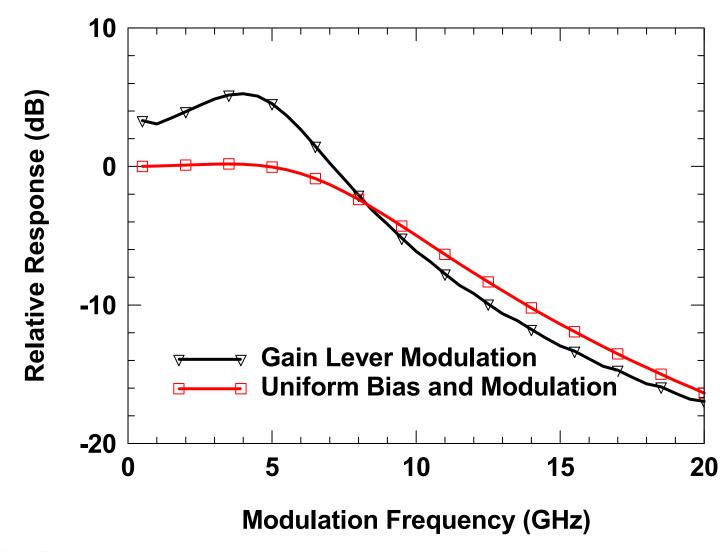
- Fabry-Perot laser model, uniform photon and carrier density
- Lumped element model adequate
- Distributed Feedback Lasers
 - Non-uniform gain due to grating feedback (SHB)
 - Distributed model needed for detailed study





Multiplex, Inc. Photonics for Communication Gain Lever Modulation Response (Preliminary Results)











Conclusion



- Established a large-signal time-domain model for travelingwave EAM
- Developed a comprehensive FDTD model for directly modulated DFB laser that is capable of simulating
 - Strong optical injection locking
 - Split-contact modulation
 - Non-uniform photon and carrier distribution in DFB
 - Spatial hole burning, gain saturation, AR-HR coating
 - Nonlinear distortion
 - RIN
- Established an automated experimental testbed for characterizing injection-locked lasers
 - Enable us to investigate detailed locking behavior over a wide range of parameter space



